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Komatsu

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(54) **IN-PLANE SWITCHING MODE LIQUID CRYSTAL DISPLAY DEVICE WITH SPECIFIC ARRANGEMENT OF COMMON BUS LINE, DATA ELECTRODE AND COMMON ELECTRODE**

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This patent is subject to a terminal disclaimer.

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(30) Foreign Application Priority Data

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Jul. 31, 1997 (KR)	97-36569

(51) **Int. Cl.⁷** **G02F 1/1343**

(52) **U.S. Cl.** **349/141; 349/38; 349/138**

(58) **Field of Search** **349/38, 39, 42, 349/43, 141, 138**

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(57) ABSTRACT

An in-plane switching mode liquid crystal display device. The device comprises first and second substrates, a plurality of gate and data bus lines formed on the first substrate to define a plurality of pixel regions, a common bus line aligned in each pixel regions of the first substrate, a thin film transistor (TFT) formed at each pixel regions of the first substrate, a data electrode which is formed on a gate insulator of the TFT and has a portion overlying the common bus line for forming a first storage capacitor, a passivation layer formed over the data electrode and the TFT, a common electrode which is formed on the passivation layer so as to overlap the gate and data bus lines and has a portion overlying the data electrode for forming a second storage capacitor, and a liquid crystal layer formed between the first and second substrates.

27 Claims, 14 Drawing Sheets

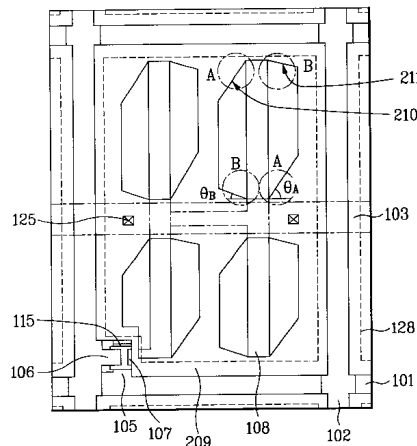


FIG. 1a
PRIOR ART

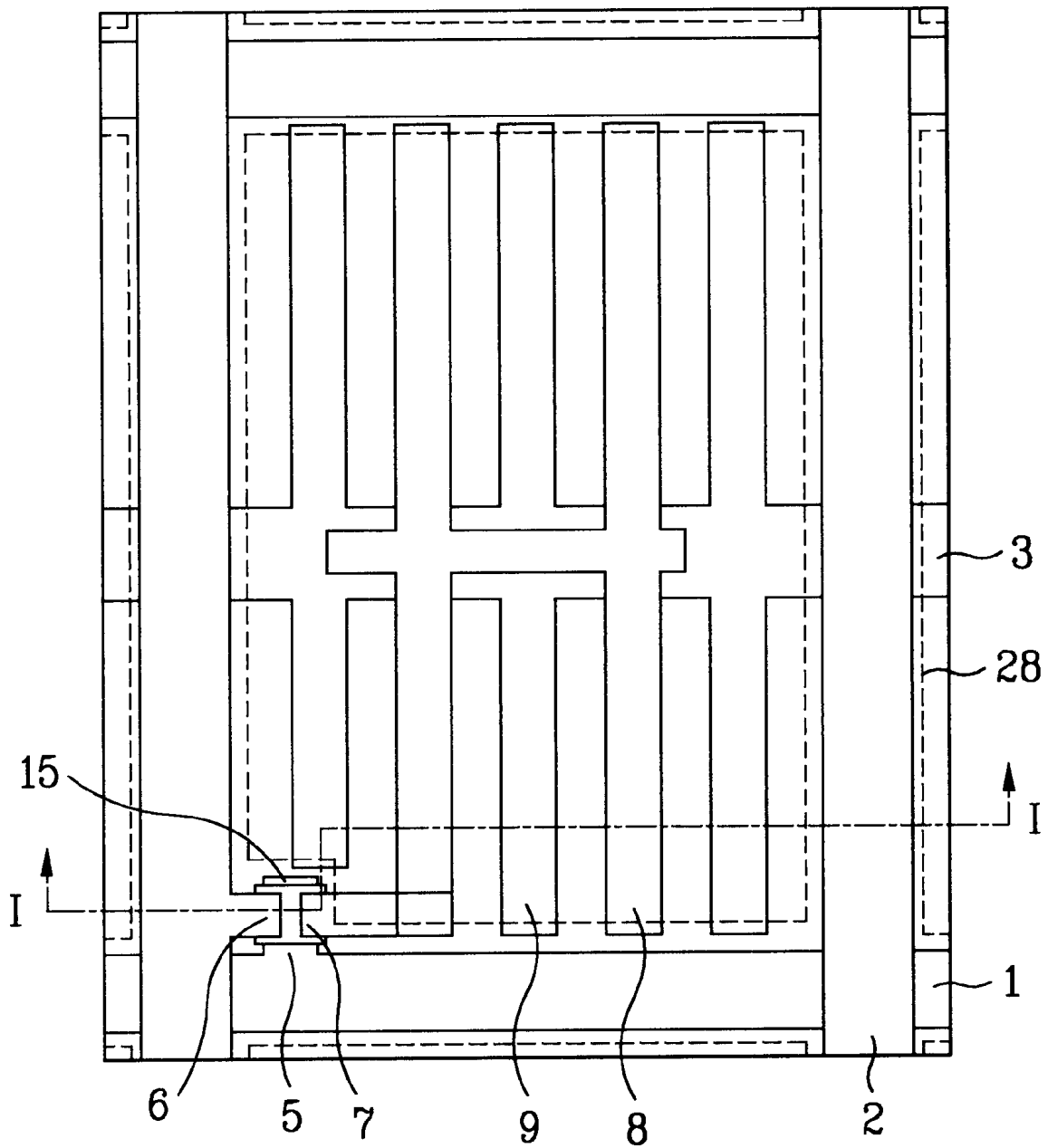


FIG. 1b
PRIOR ART

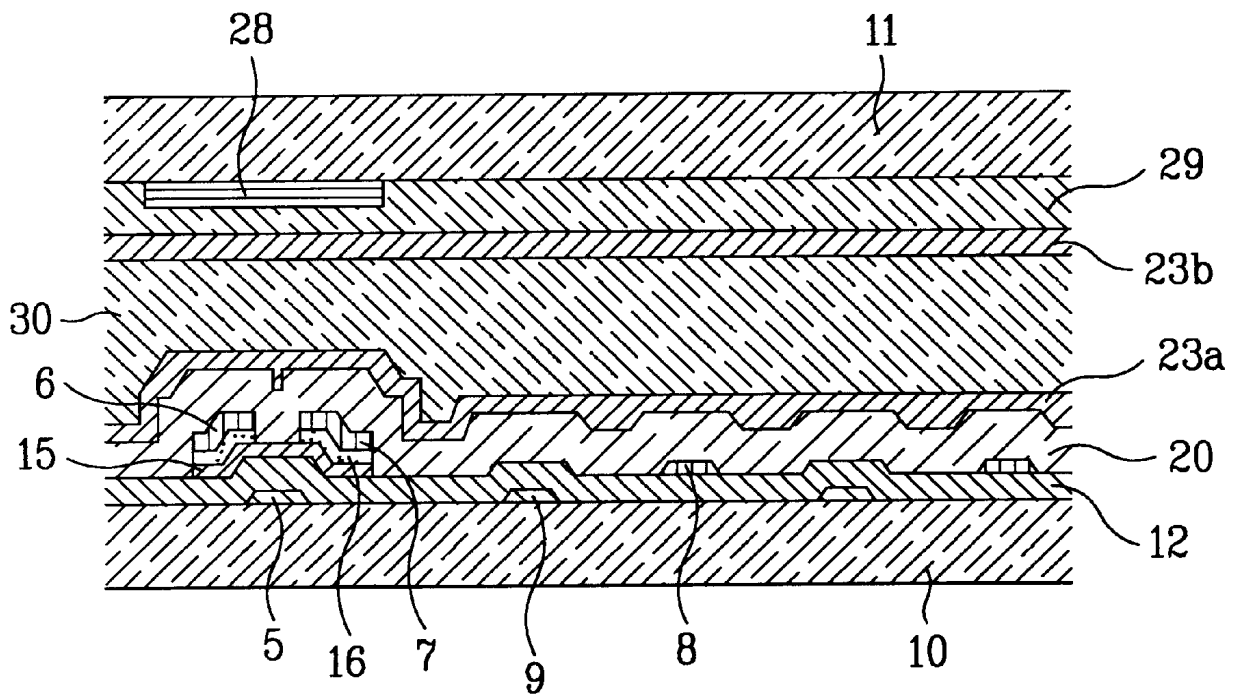


FIG. 2a

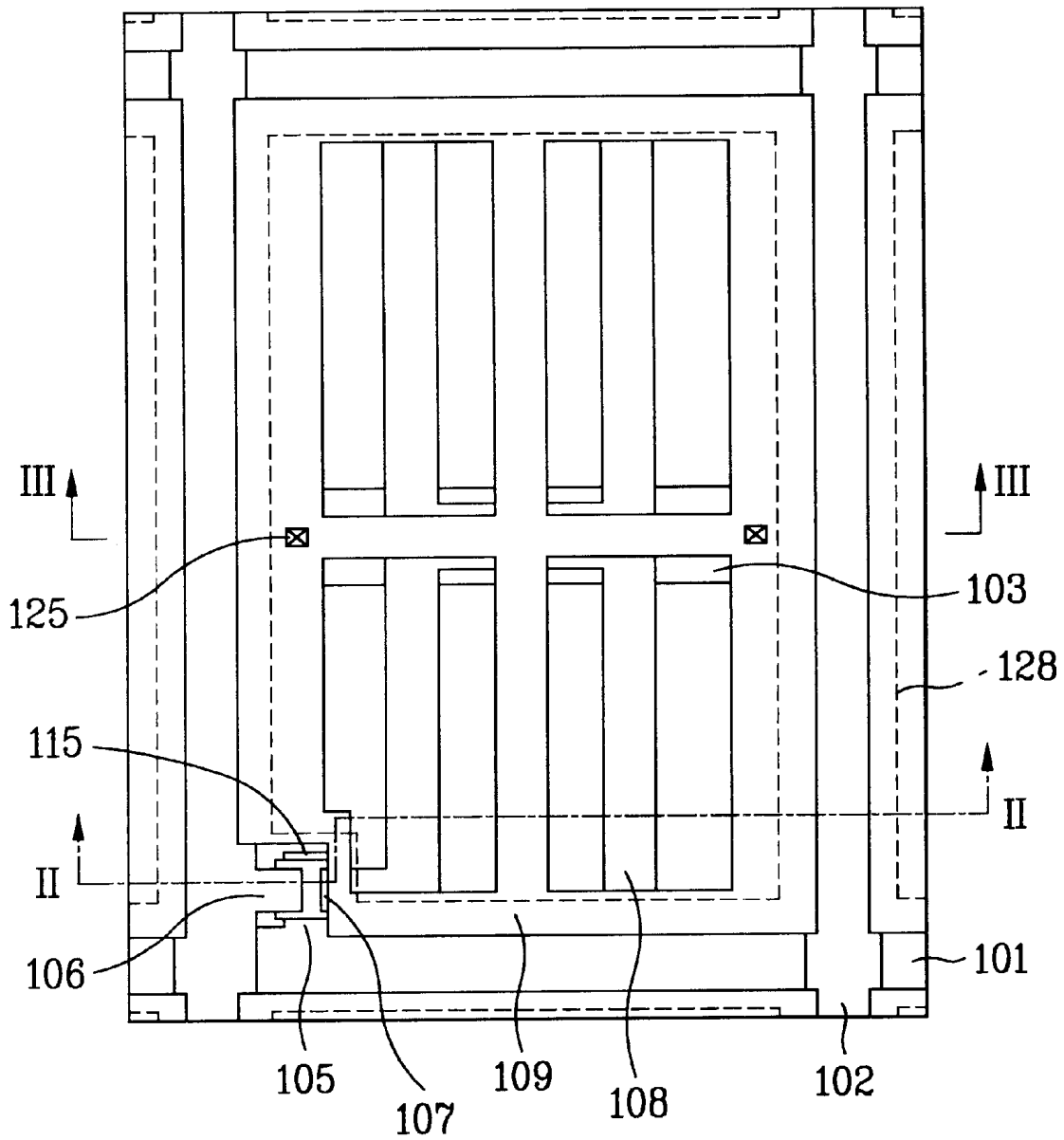


FIG. 2b

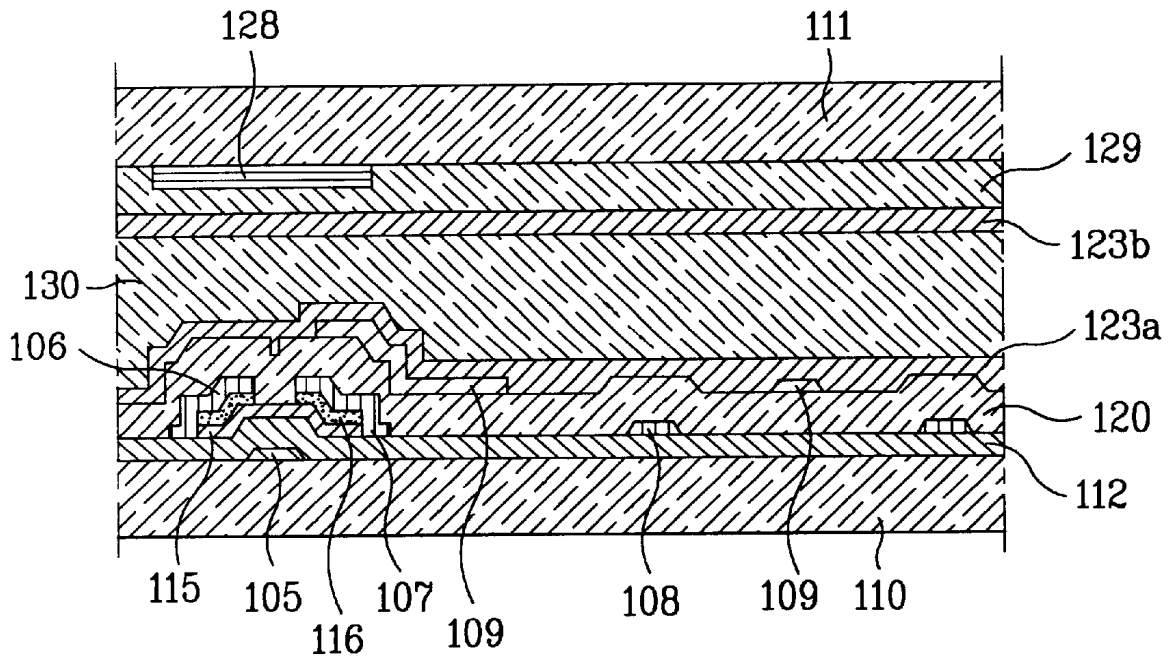


FIG. 2c

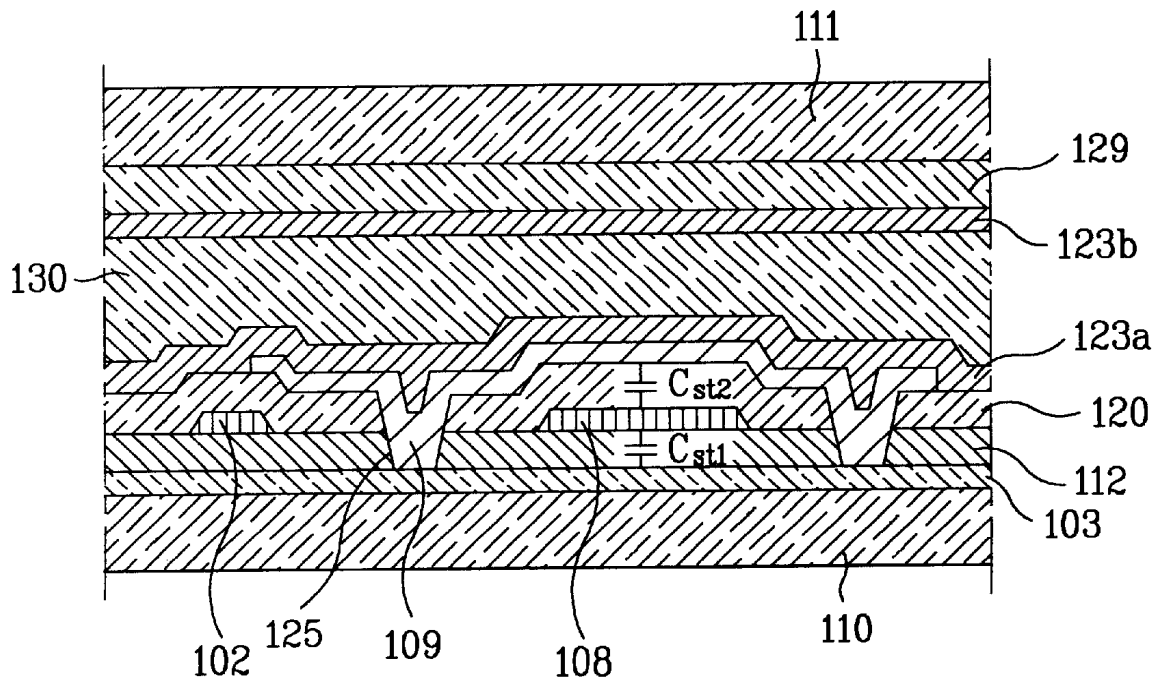


FIG. 3

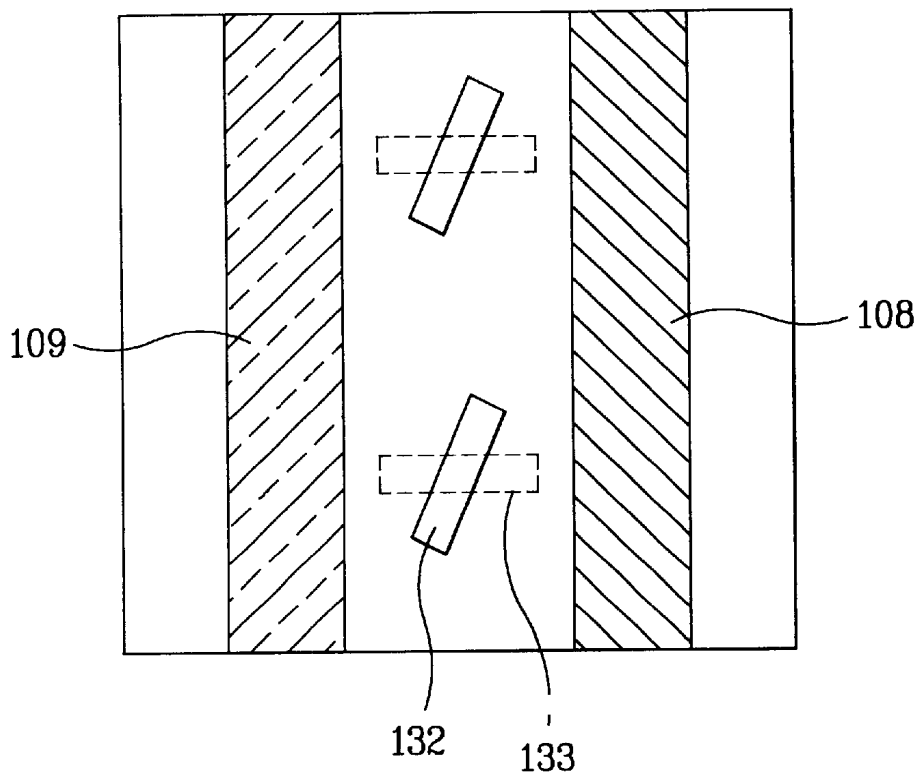


FIG. 4

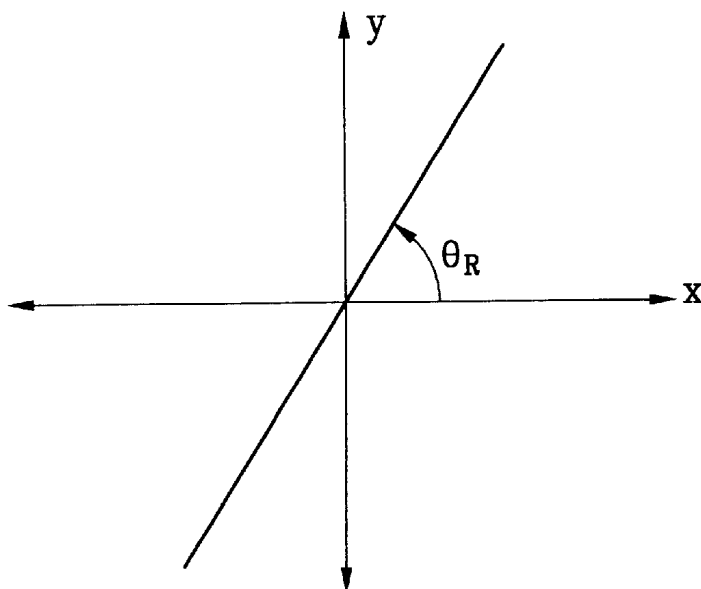


FIG. 5

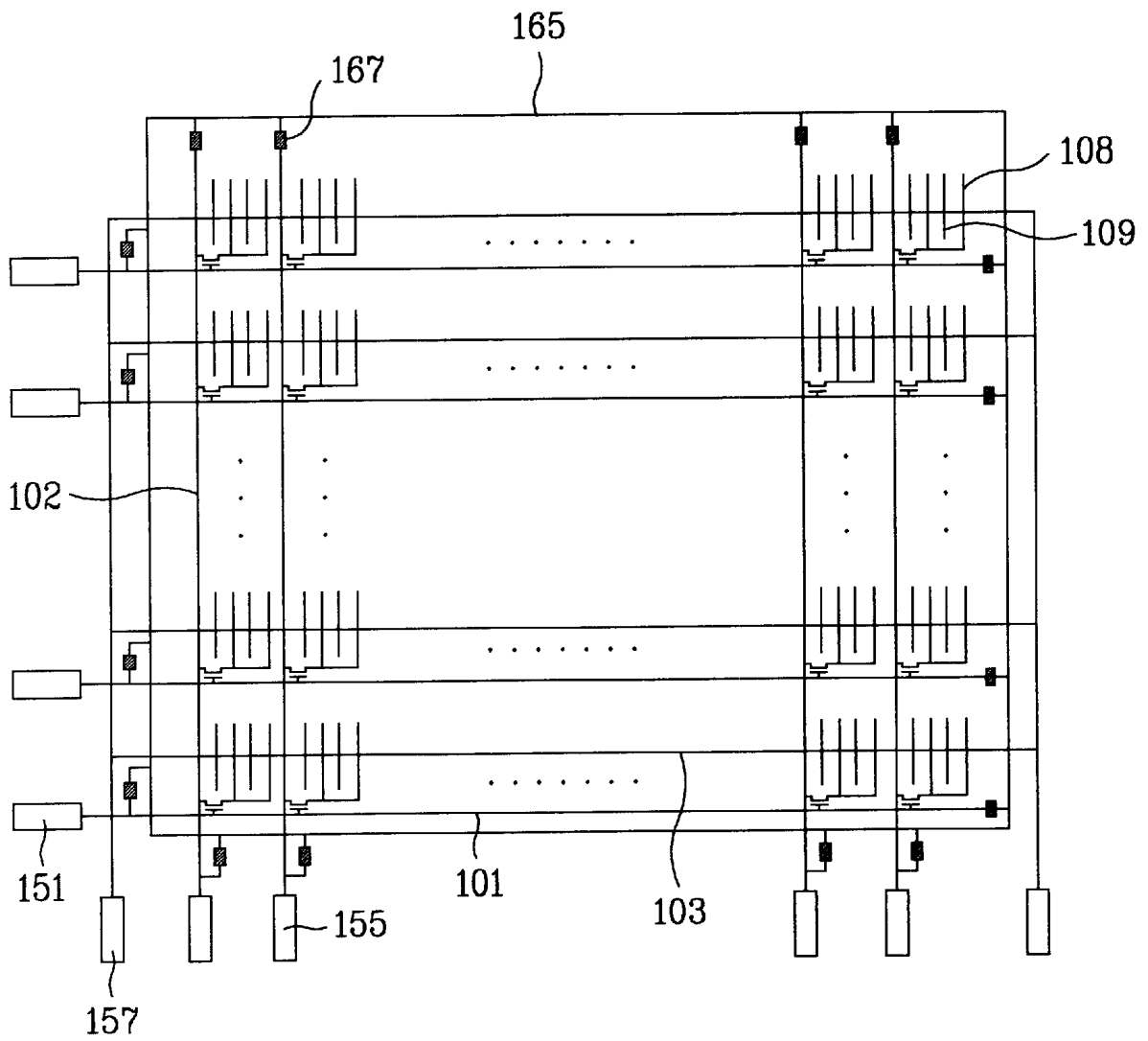


FIG. 6a

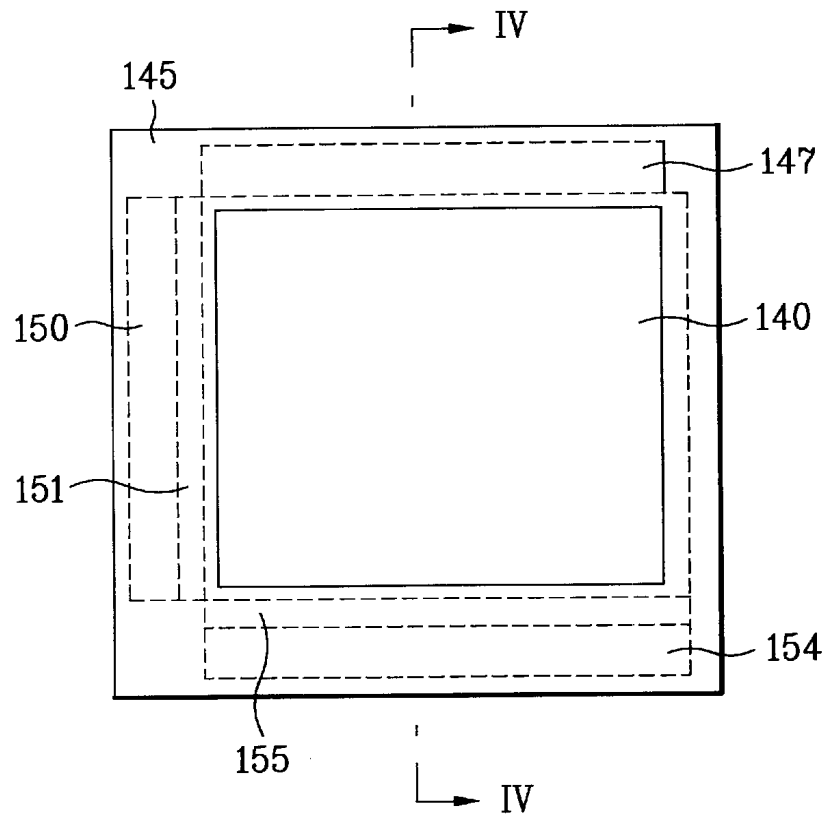


FIG. 6b

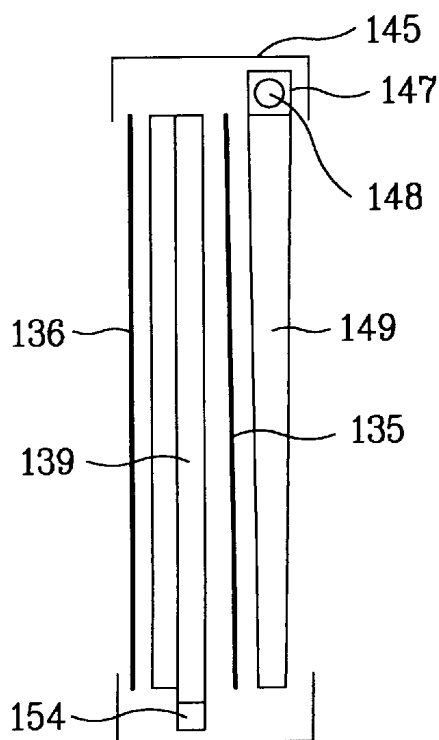


FIG. 9a

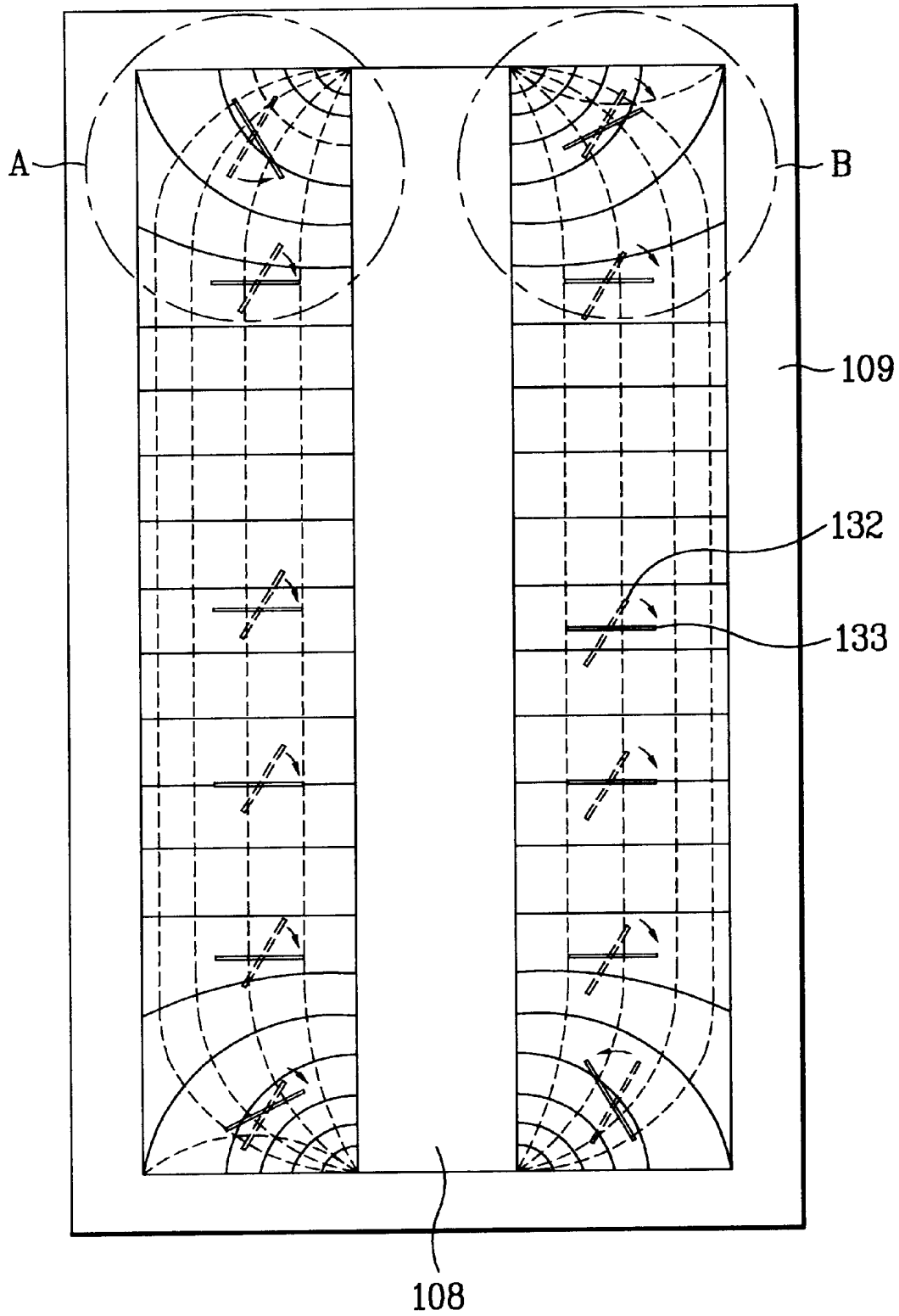


FIG. 9b

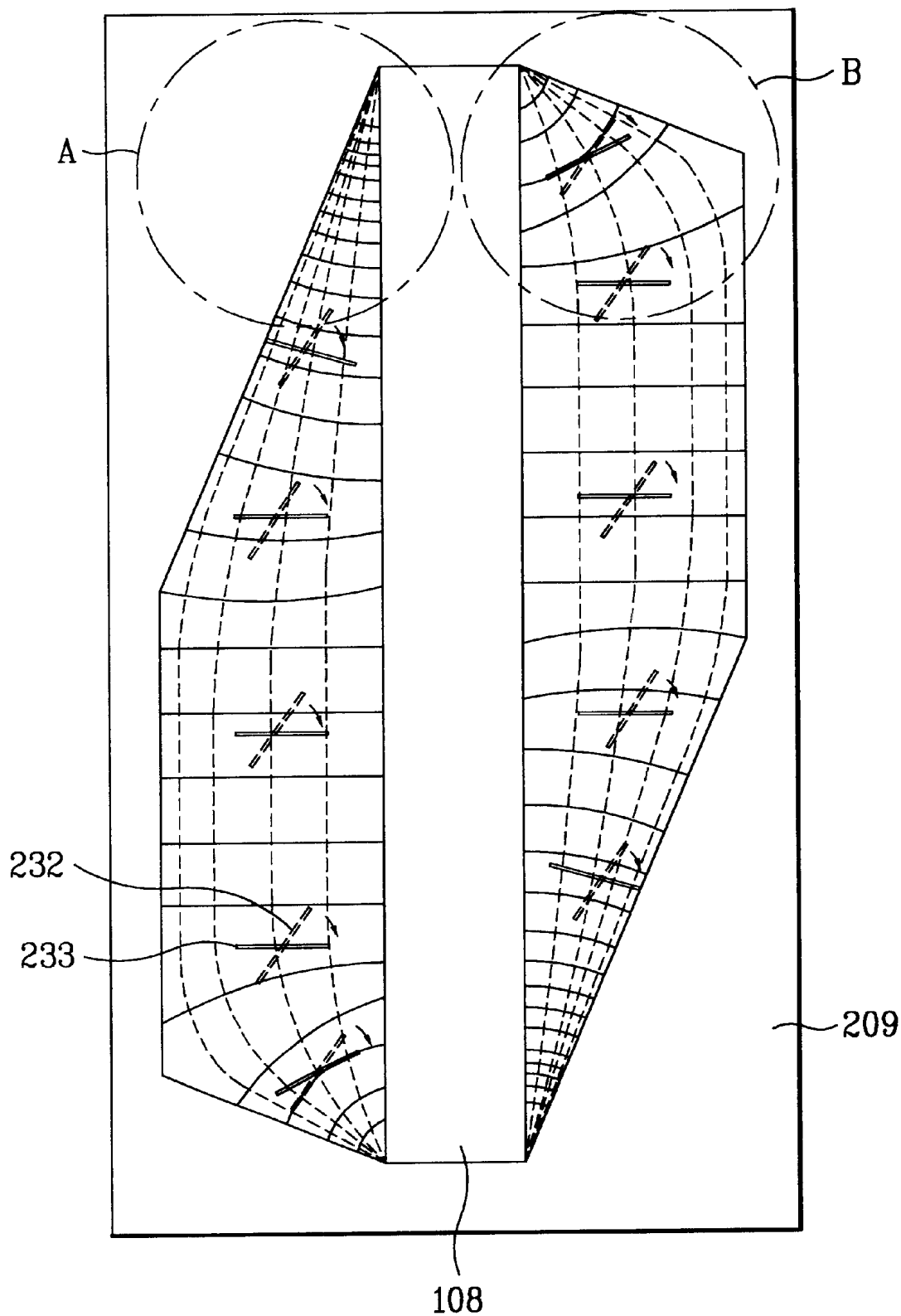


FIG. 10a

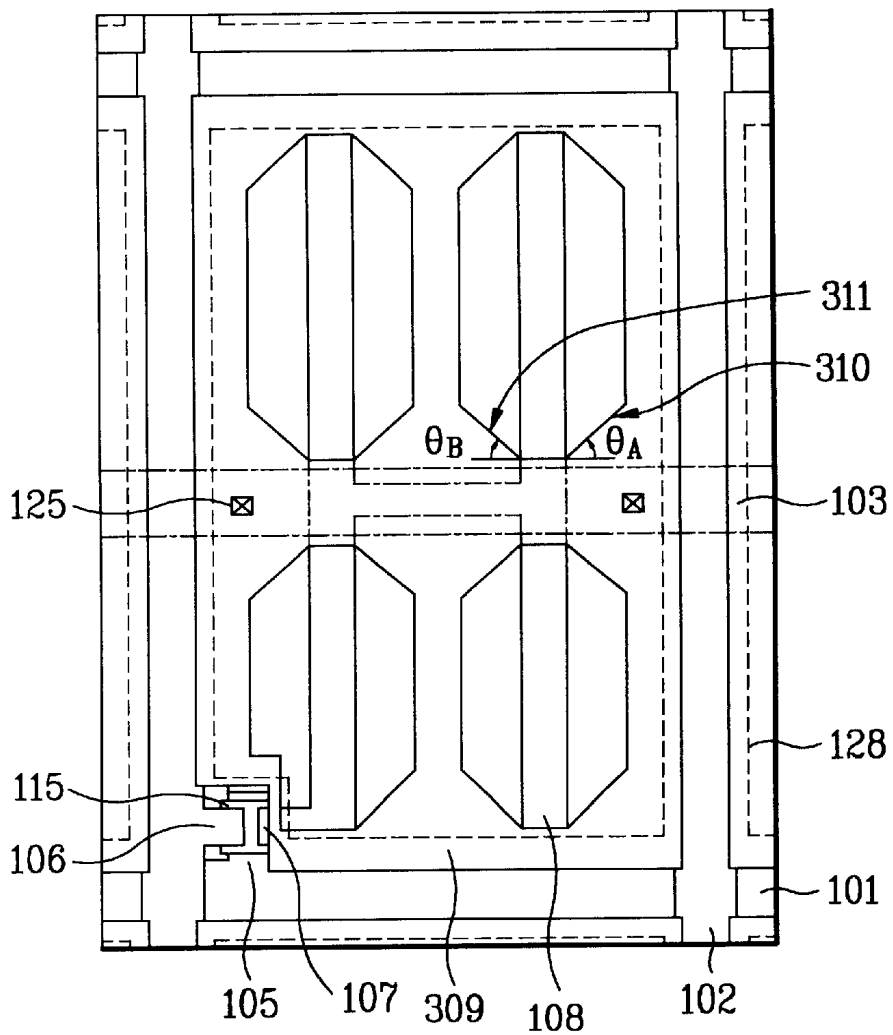


FIG. 10b

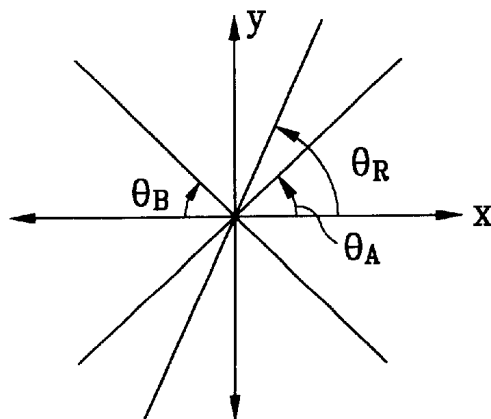


FIG. 11a

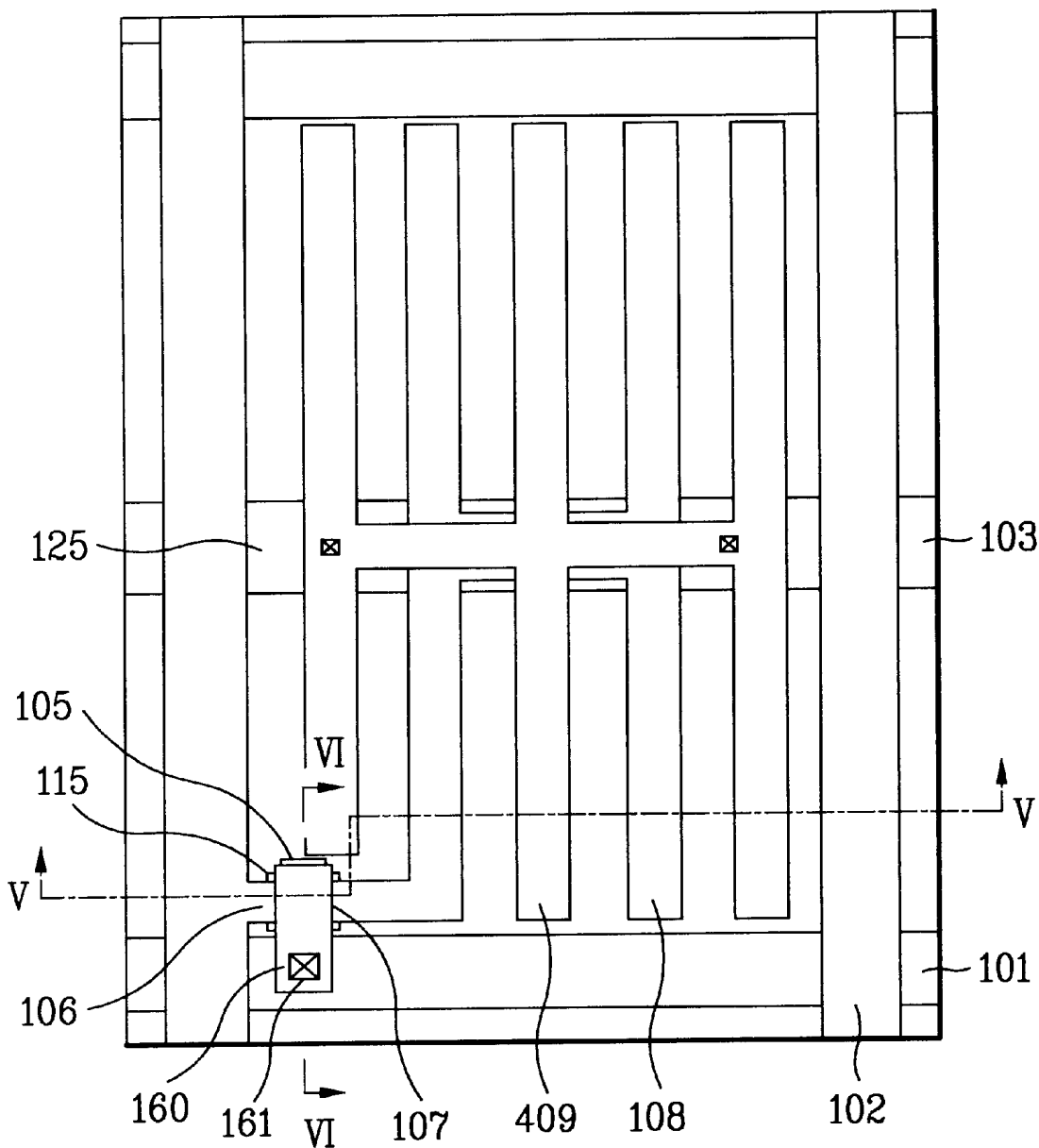


FIG. 11b

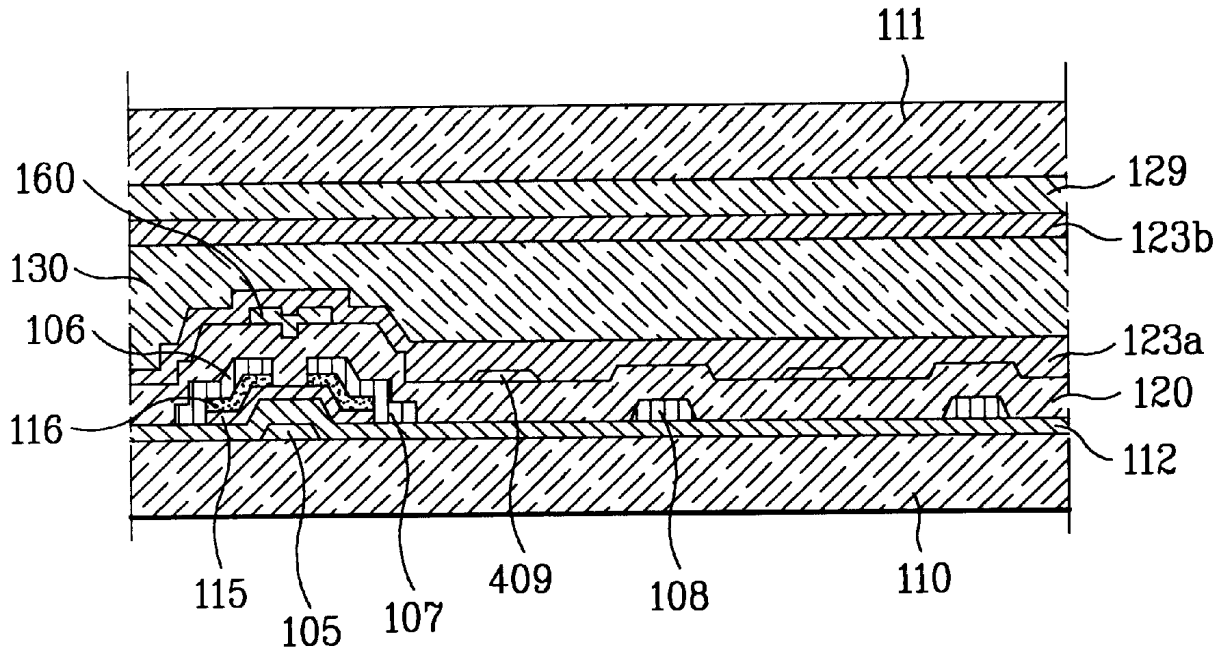


FIG. 11c

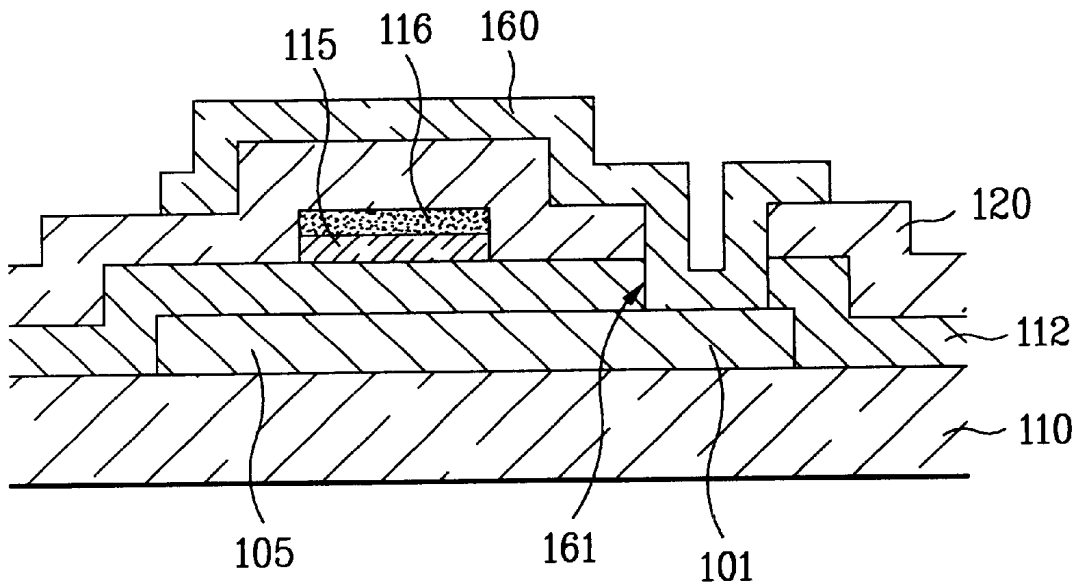
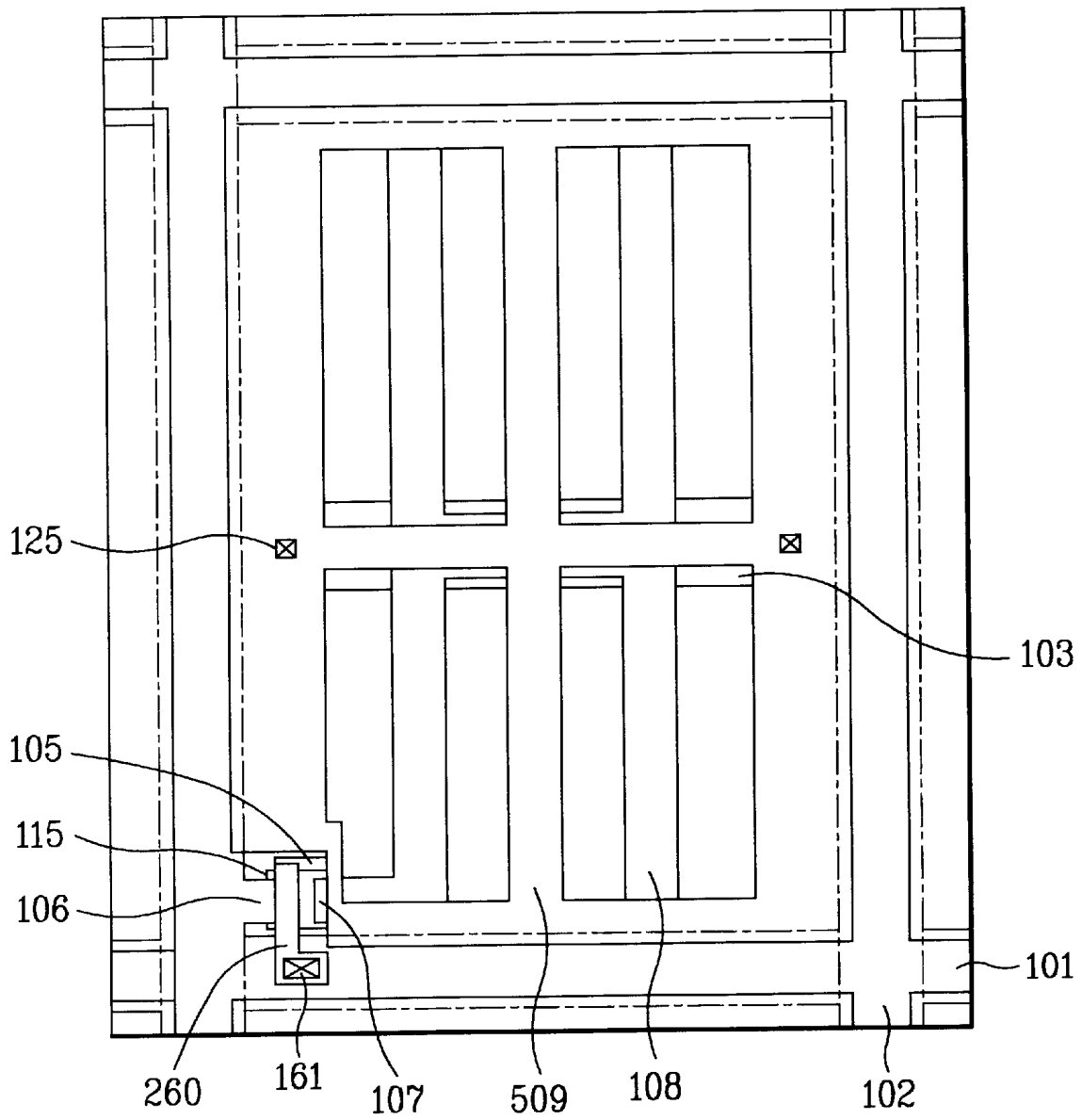


FIG. 12



**IN-PLANE SWITCHING MODE LIQUID
CRYSTAL DISPLAY DEVICE WITH
SPECIFIC ARRANGEMENT OF COMMON
BUS LINE, DATA ELECTRODE AND
COMMON ELECTRODE**

This application is a Continuation of application Ser. No. 09/116,707 Filed on Jul. 17, 1998 now U.S. Pat. No. 6,335,770.

BACKGROUND OF THE INVENTION

A. Field of the Invention

The present invention relates to a liquid crystal display device, and more particularly to an in-plane switching mode liquid crystal display device.

B. Description of the Related Art

Recently, the thin film transistor liquid crystal display devices (TFT LCDs) have been used as display devices in such applications as portable televisions and notebook computers, but these TFT LCDs have small viewing angles.

In order to solve this problem, twisted nematic LCDs having, for example, optical compensation plates and multi-domains, have been introduced. In these LCDs, however, the color of the image is shifted because the contrast ratio depends on the viewing angle direction.

For a wide viewing angle, the in-plane switching mode LCD is disclosed, for example, in JAPAN DISPLAY 92 page 547, Japanese Patent Unexamined Publication No. 7-36058, Japanese Patent Unexamined Publication No. 7-225388, and ASIA DISPLAY 95 page 707.

FIG. 1a and FIG. 1b are respectively plane and sectional views of the conventional in-plane switching mode liquid crystal display device (IPS mode LCD). FIG. 1b is a sectional view taken along line A-A' of FIG. 1a. As shown in these figures, a gate bus line 1 and a data bus line 2 are formed on a first substrate 10, defining a pixel. Although only one pixel is shown in the figures, a liquid crystal display device generally has a plurality of pixels. A common bus line 3 is aligned in the pixel, being parallel to gate bus line 1. A thin film transistor (TFT) is disposed at the intersection of gate and data bus lines 1 and 2. As shown in FIG. 1b, the TFT comprises a gate electrode 5, a gate insulator 12, a semiconductor layer 15, and an n⁺ semiconductor layer 16, a source electrode 6, and a drain electrode 7. In the pixel, a data electrode 8 and a common electrode 9 are formed parallel to data bus line 2. A portion of data electrode 8 which overlaps common bus line 3 is formed to obtain a storage capacitor, which functions as maintaining a grey level voltage applied into data electrode 8. Common electrode 9 is connected to common bus line 3. Data electrode 8 is formed on gate insulator 12 and is connected to drain electrode 7. The TFT, data electrode 8 and gate insulator 12 are covered with a passivation layer 20. Thereon, a first alignment layer 23a is coated to determine the alignment direction.

On a second substrate 11, a black mask 28 is formed to prevent a leakage of light through the regions of the TFT and gate and data bus lines 1 and 2. Thereon, a color filter layer 29 and a second alignment layer 23b are formed. Between first and second substrates 10 and 11, a liquid crystal layer 30 is formed.

When a voltage is applied to the conventional IPS mode LCD, electric field parallel to substrates 10 and 11 is generated between data and common electrodes 8 and 9. Liquid crystal molecules in the pixel are rotated according to

the electric field, controlling the amount of light passing through liquid crystal layer 30.

However, the conventional IPS mode LCD has the following problems.

First, because the area for storage capacitor occupies quite a portion of the pixel region and because the data and common electrodes are made of opaque metals, the aperture ratio is lowered.

Second, because the electric field applied to the LC layer is weakened by both gate insulator 12 and passivation layer 20 formed over two electrodes 8 and 9, the driving speed of the LC molecules is decreased, and consequently the driving voltage is increased.

Third, because data bus line 2 should be apart from the pixel region so as to avoid the crosstalk problem, the pixel region is decreased, thereby lowering the aperture ratio.

Fourth, when the black mask is formed on the second substrate, the fabricating cost is increased and the aperture ratio is lowered to compensate for the imprecise lamination of the two substrates.

SUMMARY OF THE INVENTION

An object of the present invention is to provide an in-plane switching mode liquid crystal display device wherein the aperture ratio is improved.

Another object of the present invention is to provide an in-plane switching mode liquid crystal display device wherein the driving voltage is decreased.

A further object of the present invention is to reduce the fabricating cost of provide an in-plane switching mode liquid crystal display device.

Additional objects and advantages of the invention will be set forth in part in the description which follows, and in part will be obvious from the description, or may be learned by practice of the invention. The objects and advantages of the invention will be realized and attained by means of the elements and combinations particularly pointed out in the appended claims.

To achieve the objects and in accordance with the purpose of the invention, as embodied and broadly described herein, the in-plane switching mode liquid crystal display device of the present invention comprises: a substrate; a plurality of gate and data bus lines over the substrate, defining a plurality of pixel regions; a common bus line aligned in the pixel regions; a gate insulator over the common bus line; a data electrode over the gate insulator and having a portion overlying the common bus line to form a first storage capacitor; a passivation layer over the data electrode; and a common electrode over the passivation layer at least partially overlying the gate and data bus lines and at least partially overlying the data electrode to form a second storage capacitor.

According to another aspect of the present invention, the in-plane switching mode liquid crystal display device comprises: a substrate; a plurality of gate and data bus lines over the substrate, defining a plurality of pixel regions; a common bus line aligned in the pixel regions; a gate insulator over the common bus line; a thin film transistor coupled to each of the pixel regions and including at least a part of the gate insulator; a data electrode over the gate insulator and having a portion overlying the common bus line to form a first storage capacitor; a passivation layer over the data electrode and the thin film transistor; a common electrode over the passivation layer and at least partially overlying the data electrode to form a second storage capacitor; and a metal layer over the passivation layer and the thin film transistor.

According to a further aspect of the present invention, the in-plane switching mode liquid crystal display device comprises: first and second substrates having a plurality of pixel regions; a common bus line aligned in the pixel regions; a first insulating layer over the common bus line; a data electrode over the first insulating layer and having a portion overlying the common bus line to form a first storage capacitor; a second insulating layer over the data electrode; a common electrode over the second insulating layer, the common electrode having one or more openings, at least one of the openings having a substantially rectangular shape with four corner areas, at least one corner area being cut at an angle, and the common electrode having a portion overlying the data electrode to form a second storage capacitor; and a liquid crystal layer formed between the first and second substrates.

It is to be understood that both the foregoing general description and the following detailed description are exemplary and explanatory only and are not restrictive of the invention, as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

The accompanying drawings, which are incorporated in and constitute a part of this specification, illustrate embodiments of the invention and together with the description, serve to explain the principles of the invention.

In the figures,

FIG. 1a and FIG. 1b are respectively plane and sectional views of the conventional in-plane switching mode liquid crystal display device;

FIG. 2a is a plane view showing a first embodiment of the present invention;

FIG. 2b and FIG. 2c are respectively sectional views taken along line B-B' and C-C' of FIG. 2a;

FIG. 3 is a view showing the operation of liquid crystal molecules in the first embodiment;

FIG. 4 is a view showing the alignment direction in the first embodiment;

FIG. 5 is a plane view of the TFT array structure of the present invention;

FIG. 6a and FIG. 6b are respectively plane and sectional views showing the structure of the IPS mode LCD according to the present invention;

FIG. 7 is a plane view of a second embodiment of the present invention;

FIG. 8 is a view showing the alignment direction and the direction of first and second oblique sides of the second embodiment;

FIG. 9a and FIG. 9b are views showing the direction of electric field and the operation of LC molecules in the first and second embodiments respectively;

FIG. 10a is a plane view showing a third embodiment of the present invention;

FIG. 10b is a view showing the alignment direction and the direction of first and second oblique sides of the third embodiment;

FIG. 11a is a plane view showing a fourth embodiment of the present invention;

FIG. 11b and FIG. 11c are respectively sectional views taken along lines E-E' and F-F' of FIG. 11a; and

FIG. 12 is a plane view showing a fifth embodiment of the present invention.

DETAILED DESCRIPTION

Hereinafter, in-plane switching mode LCDs according to the present invention are described in detail accompanying the figures.

FIG. 2a, FIG. 2b and FIG. 2c are views showing a first embodiment according to the present invention, where FIG. 2b and FIG. 2c are respectively sectional views taken along line B-B' and line C-C' of FIG. 2a. As shown in these figures, gate and data bus lines **101** and **102** are formed on a first substrate **110**, defining a pixel. Although only one pixel is drawn in these figures, the liquid crystal display device generally has a plurality of pixels. In the pixel, a common bus line **103** is formed parallel to gate bus line **101**. At the intersection of gate and data bus lines **101** and **102**, a thin film transistor (TFT) is formed as shown in FIG. 2b which comprises a gate electrode **105**, a gate insulator **112**, a semiconductor layer **115**, an n⁺ semiconductor layer **116**, a source electrode **106**, and a drain electrodes **107**. In the pixel, data and common electrodes **108** and **109** are disposed parallel to data bus line **102**. Over the TFT and data electrode **108**, a passivation layer **120** is formed, and common electrode **109** is formed thereon to be parallel to data electrode **108** and overlap gate and data bus lines **102** and **103**. Over common electrode **109** and passivation layer **120**, a first alignment layer **123a** is formed.

As in the conventional IPS mode LCD, data electrode **108** has a portion overlapping common bus line **103** for obtaining a first storage capacitor (C_{st1}) as shown in FIGS. 2a and 2c. In addition, common electrode **109** has a portion overlapping data electrode **108** for obtaining a second storage capacitor (C_{st2}).

Common electrode **109** is connected to common bus line **103** through a first hole **125** which is formed in passivation layer **120** and gate insulator (layer) **112**. Common electrode **109** also overlaps gate and data bus lines **101** and **102**. Thus, it functions to block the electric effect of two bus lines **101** and **102** to prevent the crosstalk problem.

Gate electrode **105**, gate bus line **101**, and common bus line **103** are formed by patterning double metal layers (Mo/Al) which is deposited by sputtering an Al layer having a thickness of 2000 Å and a Mo layer having a thickness of 1000 Å in the named order. Gate insulator **112** is formed thereon by depositing an inorganic insulating layer such as silicon nitride having a thickness of 4000 Å by a chemical vapor deposition method. A semiconductor layer **115** and an n⁺ semiconductor layer **116** are formed by depositing and etching an amorphous silicon (a-Si) layer having a thickness of 1700 Å and an n⁺ a-Si layer having a thickness of 300 Å. Data bus line **102**, data electrode **108**, source electrode **106**, and drain electrode **107** are formed by depositing and etching a Cr metal layer having a thickness of 1500 Å. Also, the gate and data bus line may be formed of high conductive metal layers such as Mo metal layer, Mo/Al/Mo triple metal layers, or Cr/Al/Cr triple metal layers in order to prevent signal delay in the gate and data bus lines which is generated by being overlapped with the common electrode.

The TFT and data electrode **108** are covered with a passivation layer **120** such as silicon oxide and silicon nitride having a thickness of 2000 Å. On passivation layer **120**, common electrode **109** is formed by depositing and etching a transparent conducting layer such as indium tin oxide (ITO) having a thickness of 500 Å.

Over common electrode **109** and passivation layer **120**, a first alignment layer **123a** is formed by coating polyimide or polyamide or photo-alignment materials. The polyimide or polyamide alignment layer is rubbed to impart an alignment direction thereto. On the other hand, the photo-alignment layer such as polyvinylcinnamate (PVCN) or polysiloxane based materials is exposed to an ultraviolet light to impart an alignment direction thereto.

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As shown in FIG. 2c, data and common electrodes **108** and **109** have portions for first and second storage capacitors whose capacitances are C_{st1} and C_{st2} respectively. Accordingly, the total storage capacitance (C_{st}) in the present invention becomes the sum of storage capacitances C_{st1} and C_{st2} . The storage capacitor (C_{st}) is double the conventional storage capacitor (C_{st1}), so that the area for storage capacitor can be reduced to half the conventional area, thereby improving the aperture ratio.

As shown in FIG. 2b, on a second substrate **111**, a black mask **128** and a color filter layer **129** are formed. An overcoat layer may be formed thereon to flatten and stabilize the surface. Black mask **128** prevents a leakage of light through the regions of TFT and gate, data and common bus lines **101**, **102**, and **103**. Black mask **128** is made of a Cr or a CrOx metal layer having a thickness of $0.1\ \mu\text{m}$ and a width of $10\ \mu\text{m}$. Color filter layer **129** has one of R, G, and B color filter elements in each pixel. On color filter layer **129**, a second alignment layer **123b** is formed by coating polyimide or photo-alignment materials. Second alignment layer **123b** is rubbed or exposed to UV light to impart an alignment direction. A liquid crystal layer **130** is inserted between two substrates **110** and **111** by injecting liquid crystal in vacuum state.

FIG. 3 is a view showing the operation of liquid crystal molecules in the IPS mode LCD according to the present invention. FIG. 4 is a view showing the alignment direction, where the Y axis direction indicates the extension direction of data and common electrodes **108** and **109**, and θ_R indicates the angle between the alignment direction and the X axis direction, which is the extension direction of data bus line **102**. When a voltage is not applied to the device, the liquid crystal molecules are aligned according to the alignment direction. When a voltage is applied to the device, electric field parallel to the substrates is generated between common and data electrodes **109** and **108**, and thereby liquid crystal molecules **132** rotates clockwise according to the electric field. In FIG. 3, a reference number **133** indicates the positions of the liquid crystal molecules after applying the voltage.

FIG. 5 is a view showing the TFT array structure of the present invention. Gate and data bus lines **101** and **102** are connected to gate and data driving circuits through gate and data pads **151** and **155** respectively. Gate and data bus lines **101** and **102** are connected to a grounding wiring **165** through an electrostatic discharging circuit **167** composed of TFT. Also common bus line **103** is grounded through common pad **157**.

Although not illustrated in the figure, gate, data and common pads **151**, **155** and **157** are made of first, second and third metal layers. The first metal layer is formed of Mo/Al double metal layers together with gate electrode **105** and common bus line **103**, as shown in FIGS. 2a, 2b, and 2c. The second metal layer is formed of Cr together with source and drain electrode **106** and **107**. The third metal layer is formed of ITO together with common electrode **109**. In order to connect the pads to the driving circuits, it is necessary to etch gate insulator **112** and passivation layer **120** in the pad region. The two insulating layers in the pad region are etched when hole **125** is formed. In the prior art, an oxide layer is generated on the pads by the exposure to the air, causing a problem that the contacting electric resistance is increased when connecting the pads to the driving circuits. However, in this embodiment, because the third metal layer of the pads is made of ITO to obtain an IOP (ITO On Passivation) structure, the above-mentioned problem is not generated.

FIG. 6a and FIG. 6b are plane and sectional views showing the structure of the in-plane switching mode LCD

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consistent with the present invention, where FIG. 6b is a sectional view taken along line D-D' of FIG. 6a. As shown in these figures, gate and data driving circuits **150** and **154** are disposed in a frame **145** outside display region **140**. Gate and data driving circuits **150** and **154** are connected to gate and data bus lines **101** and **102** through gate and data pads **151** and **154** respectively. A backlight housing **147** is disposed on the upper side of frame **145**. In backlight housing **147**, a backlight **148** is disposed to project a light into a liquid crystal panel **139** through a light pipe **149**. Between light pipe **149** and liquid crystal panel **139**, a polarizer **135** is disposed to polarize the light linearly. An analyzer **136** is disposed on the front of panel **139**.

The advantages of the first embodiment according to the present invention are summarized as follows.

First, passivation layer **120** and gate insulator **112** (shown in FIGS. 2b and 2c) do not absorb the electric field applied to liquid crystal layer **130** because common electrode **109** is disposed above two insulating layers **112** and **120**. Accordingly, the driving voltage is lowered.

Second, because the areas for storage capacitor can be decreased, the aperture ratio is much more improved.

Third, because common electrode **109** overlaps gate and data bus lines **101** and **102** to block the electric effect of two bus lines **101** and **102**, the crosstalk problem can be eliminated. Accordingly, the pixel region can be enlarged, improving the aperture ratio.

Fourth, because common electrode **109** is formed of ITO to obtain an IOP structure, the contacting electric resistance between the pads and the driving circuits is decreased, and the aperture ratio is improved.

FIG. 7 is a view showing a second embodiment of the present invention. Hereinafter, constituent elements similar to those of the first embodiment are denoted by the same reference numbers. As shown in this figure, this embodiment differs from the first embodiment in that a common electrode **209** has first and second oblique sides **210** and **211**. FIG. 8 is a view showing the alignment direction and the direction of the first and second oblique sides of the second embodiment, where Y axis indicates the extension direction of the data electrode **108**. In region A of FIG. 7, first oblique side **210** is inclined counterclockwise from the X axis with an angle θ_A . In region B, second oblique side **210** is inclined clockwise from the X axis with an angle θ_B . The alignment direction is determined to be inclined counterclockwise to X axis direction with an angle θ_R in the range of 0 to 90° . Angle θ_A is determined to be in the range of θ_R to 90° . The angle θ_B is determined to be in the range of $90^\circ - \theta_R$ to 90° . The figures show a case where the angle θ_R is larger than 45° , and therefore the angle θ_A is larger than the angle θ_B . On the contrary, when the angle θ_R is smaller than 45° , the angle θ_B is determined to be larger than the angle θ_A .

The object of this embodiment is to prevent the problem of the first embodiment, in which disclination may be generated in the region where common electrode **209** crosses with data electrode **109**.

In the first embodiment, the electric field is generated between common and data electrodes **108** and **109** as shown in FIG. 9a. In the middle region of the opening portion, the direction of electric field is perpendicular to the extension direction of electrodes **108** and **109**. When voltage is applied to the device, in the middle region, LC molecules **132** are given a clockwise turning force according to the electric field perpendicular to the extension direction of electrodes **108** and **109**, and thereby they rotate clockwise to be aligned perpendicular to the extension direction of the electrodes.

On the other hand, in regions A and B where common electrode **109** crosses with data electrode **108**, an electric field is deformed not to be perpendicular to the extension direction of electrodes **108** and **109**. When the voltage is applied to electrodes **108** and **109**, in regions A and B, LC molecules **132** are aligned to be different from the middle region. Particularly in the region bounded by chain lines, the LC molecules are given with a counterclockwise turning force according to the deformed electric field, and thereby they rotate in opposite direction to those in the middle region. Consequently, in the border region denoted by chain lines, the alignment of LC molecules **132** is not defined, thereby generating disclination. Particularly when using liquid crystal having a low viscosity for lowering the driving voltage, since the interaction between LC molecules **132** is weak, a possibility of generating the disclination is increased to deteriorate the image quality. In this figure, reference number **133** denotes LC molecules after applying the voltage.

However, in the second embodiment, since common electrode **209** has first and second oblique sides **210** and **211**, as shown in FIG. 7, the electric field is slightly deformed in regions A and B, as shown in FIG. 9b. The electric field gives a clockwise turning force to LC molecules **232** in regions A and B. Accordingly, although using liquid crystal having a low viscosity for lowering the driving voltage, LC molecules **232** in regions A and B rotate in the same direction with those in the middle region, thereby preventing the disclination. In FIG. 9b, reference number **233** denotes LC molecules after applying the voltage.

The second embodiment has an aperture ratio lower than the first embodiment, and however has a more improved image quality by preventing the disclination. In this case, it is preferable to form common electrode **209** out of ITO for improving the aperture ratio.

FIG. 10 is a view showing a third embodiment. This embodiment is similar to the second embodiment except for angles θ_A and θ_B of common electrode **309**. In this embodiment, angles θ_A , θ_B and θ_R are approximately 45°, 45°, and 75° respectively. In region B, because angle θ_B is in the range of $90^\circ - \theta_R$ to 90° , the LC molecules are given with a clockwise turning force, thereby not generating the disclination. On the other hand, in region A, since the angle θ_A is out of the range of θ_R to 90° , the LC molecules are given a counterclockwise turning force.

However, the disclination is not generated in the region A because there is an interaction between the liquid crystal molecules when using a usual liquid crystal.

FIGS. 11a, 11b, and 11c are plane and sectional views showing the fourth embodiment, where FIGS. 11b and 11c are sectional views taken along lines E-E' and F-F' of FIG. 11a respectively.

In this embodiment, as shown in these figures, data and common electrodes **108** and **409** have portions for first and second storage capacitors as in the previous embodiments. This embodiment differs from the previous embodiments in that the common electrode does not overlap gate and data bus lines **101** and **102**, and a light shielding electrode **160** is formed on passivation layer **120** in the region of the TFT. Common electrode **409** and light shielding electrode **160** are formed together by sputtering and etching Mo metal layer having a thickness of 1000 Å. Because light shielding electrode **160** functions as a black mask for the TFT, as shown in FIG. 11b, the black mask is not formed in the region of TFT. To obtain an IOP structure, two electrodes **409** and **160** are formed of metal layers including ITO, and

it is preferable that they are formed of a double layer ITO/Mo which is formed by depositing Mo metal layer and ITO in the named order. Light shielding electrode **160** is formed to overlap a portion of gate bus line **101** so as to be connected with gate bus line **101** through a second hole **161** formed in gate insulator **112** and passivation layer **120**. Accordingly, light shielding electrode **160** is provided with the same voltage as gate electrode **105**.

In this embodiment, light shielding electrode **160** overlaps the TFT with passivation layer **120** interposed therebetween in order to prevent a light incident on semiconductor layer **115** of the TFT. Accordingly, there is no need to form a black mask in the region of TFT, decreasing the fabricating cost. Further, the leakage current is prevented which is generated by excitation of semiconductor layer **115** when semiconductor layer **115** is exposed to light, so that a backlight having a high light intensity can be used improving the luminosity of the device.

In addition, since light shielding electrode **160** is connected with the gate bus line for obtaining the same voltage as gate electrode **105**, it functions as a back gate electrode increasing the switching current of the TFT. Accordingly, switching speed of the TFT is increased so that the same switching speed as the prior art can be obtained using TFT of relatively small size.

FIG. 12 is a view showing a fifth embodiment. As shown in this figure, this embodiment is similar to the fourth embodiment except that a common electrode **509** overlaps gate and data bus lines **101** and **102** as in the first, second, and third embodiments.

Common electrode **509** and a light shielding electrode **260** are formed of opaque metals as the fourth embodiment, and function as a light shielding layer so that there is no need to form a black mask in the regions of the TFT, and two bus lines **101** and **102**. Accordingly, the fabricating cost for the black mask is reduced, and prevented is the conventional problem in that the aperture ratio is lowered by having to compensate for imprecise lamination when forming the black mask on the second substrate. Further, as in the fourth embodiment, light shielding electrode **260** prevents a light incident on the active layer.

In the first, second, third, and fifth embodiments, a parasitic capacitor may be formed between the common electrode and the gate and data bus lines, causing the signal delay in the two bus lines. This signal delay problem can be eliminated by forming the gate and data bus lines out of low resistance metal layers such as Mo metal layer, Mo/Al/Mo triple metal layers or Cr/Al/Cr triple metal layers.

The present invention is characterized in that the common electrode is formed on passivation layer **120**, and the data and common electrodes have portions for first and second storage capacitors. Accordingly, passivation layer **120** and gate insulator **112** do not absorb the electric field applied to liquid crystal layer **130** because the common electrode is disposed above two insulating layers **112** and **120**. Accordingly, the driving voltage is lowered. Further, because the areas for storage capacitor can be decreased, the aperture ratio is much more improved. Furthermore, because the common electrode is formed out of ITO for obtaining IOP structure, the contacting electric resistance between the pads and the driving circuits **16** decreased as well as the aperture ratio is improved.

In first, second, third, and fifth embodiments according to the present invention, because the common electrode overlaps the gate and data bus lines to block the electric effect of the two bus lines, the crosstalk problem can be removed. Accordingly, the pixel region can be enlarged improving the aperture ratio.

In fourth and fifth embodiments, the light shielding electrode functions as a back gate electrode for increasing the switching speed of TFT, and prevents a leakage current caused by excitation of the active layer. Particularly in the fifth embodiment, since the light shielding electrode and the common electrode function as a black mask, there is no need to form the black mask in the regions of TFT and the two bus lines **101** and **102**, removing the problems generated when forming the black mask on the second substrate.

It will be apparent to those skilled in the art that various modifications and variations can be made in the in plane switching mode liquid crystal display device of the present invention and in construction of this device without departing from the scope or spirit of the invention.

Other embodiments of the invention will be apparent to those skilled in the art from consideration of the specification and practice of the invention disclosed herein. It is intended that the specification and examples be considered as exemplary only, with a true scope and spirit of the invention being indicated by the following claims.

What is claimed is:

1. A liquid crystal display comprising:
 - a first substrate;
 - a second substrate;
 - a liquid crystal layer between the first substrate and the second substrate;
 - a plurality of gate bus lines and data bus lines over the first substrate defining a plurality of pixel regions;
 - a plurality of common bus lines, at least one common bus line intersecting at least one pixel region;
 - a first insulative layer over the at least one common bus line in the pixel region;
 - a data electrode over the first insulative layer, a portion of the data electrode overlying the common bus line to form a first capacitor;
 - a second insulative layer over the data electrode; and
 - a common electrode over the second insulative layer, a portion of the common electrode overlying the data electrode to form a second capacitor, the common electrode having a plurality of openings formed therein, at least one of the openings having a shape in the form of a polygon.
2. The display of claim 1, wherein the polygon has four sides.
3. The display of claim 1, wherein the polygon is a rectangle.
4. The display of claim 1, where the polygon comprises a first pair of parallel sides and at least one additional side, the at least one additional side being connected to one of the first pair of parallel sides at a first point such that an interior angle formed at the first point is obtuse.
5. The display of claim 4, wherein the polygon further comprises a second pair of parallel sides, the at least one additional side further being connected to one of the second pair of parallel sides at a second point such that an interior angle formed at the second point is also obtuse.
6. The display of claim 5, wherein the first pair of parallel sides has a first direction, the second pair of parallel sides has a second direction, and the first direction is perpendicular to the second direction.

7. The display of claim 1, wherein the polygon has eight sides.
8. The display of claim 7, wherein the eight sides comprise four pairs of parallel sides.
9. The display of claim 8, wherein both sides in a pair of parallel sides have a same length.
10. The display of claim 9, wherein all sides in at least two pairs of parallel sides have a same length.
11. A liquid crystal display, comprising:
 - a substrate;
 - a plurality of gate bus lines and data bus lines over the first substrate defining a plurality of pixel regions; each of the pixel regions having a common bus passing therethrough;
 - a first insulative layer over the common bus;
 - a data electrode over the insulative layer and a portion of the common bus to form a first capacitor;
 - a second insulative layer over the data electrode; and
 - a common electrode over the second insulative layer and a portion of the data electrode to form a second capacitor.
12. The display of claim 11, wherein a portion of the data electrode forms part of both the first and second capacitors.
13. The display of claim 12, wherein the common electrode at least partially overlies a gate bus line.
14. The display of claim 12, wherein the common electrode at least partially overlies a data bus line.
15. The display of claim 12, wherein the common electrode at least partially overlies a data bus line and a gate bus line.
16. The display of claim 12, wherein the common electrode includes a plurality of spaced apart parallel extensions in a first direction, and the data electrode includes a plurality of spaced apart parallel extensions in a second direction.
17. The display of claim 16, wherein the first direction is parallel to the second direction.
18. The display of claim 17, wherein the common electrode further includes a portion perpendicular to the parallel extensions in the first direction and the data electrode includes a portion perpendicular to the parallel extensions in the second direction.
19. The display of claim 12, wherein the common electrode includes a plurality of openings.
20. The display of claim 12, wherein the openings are in the shape of a polygon.
21. The display of claim 20, wherein the polygon has four sides.
22. The display of claim 20, wherein the polygon has more than four sides.
23. The display of claim 20, wherein the polygon has at least one pair of parallel sides.
24. The display of claim 20, wherein the polygon has at least two pairs of parallel sides.
25. The display of claim 20, wherein the polygon has at least three pairs of parallel sides.
26. The display of claim 20, wherein the polygon has at least four pairs of parallel sides.
27. The display of claim 20, wherein all interior angles of the polygon are obtuse.

专利名称(译)	面内切换模式液晶显示装置具有公共总线，数据电极和公共电极的特定布置		
公开(公告)号	US6400436	公开(公告)日	2002-06-04
申请号	US09/613730	申请日	2000-07-11
[标]申请(专利权)人(译)	乐金显示有限公司		
申请(专利权)人(译)	LG 飞利浦LCD CO. , LTD.		
当前申请(专利权)人(译)	LG DISPLAY CO. , LTD.		
[标]发明人	KOMATSU HIROSHI		
发明人	KOMATSU, HIROSHI		
IPC分类号	G02F1/13 G02F1/1343 G02F1/1362		
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优先权	1019970034196 1997-07-22 KR 1019970036569 1997-07-31 KR		
外部链接	Espacenet USPTO		

摘要(译)

一种面内切换模式液晶显示装置。该器件包括第一和第二基板，形成在第一基板上以限定多个像素区域的多条栅极和数据总线，在第一基板的每个像素区域中对准的公共总线，薄膜晶体管 (TFT) 形成在第一基板的每个像素区域的数据电极，形成在TFT的栅极绝缘体上的数据电极，具有覆盖公共总线的部分，用于形成第一存储电容器，形成在数据电极和TFT上的钝化层公共电极，形成在钝化层上，与栅极线和数据总线重叠，并具有覆盖数据电极的部分，用于形成第二存储电容器，以及形成在第一和第二基板之间的液晶层。

